Quasiparticle Transformation during a Metal-Insulator Transition in Graphene

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(Received 15 April 2009; published 29 July 2009)

Here we show, with simultaneous transport and photoemission measurements, that the graphene-terminated SiC(0001) surface undergoes a metal-insulator transition upon dosing with small amounts of atomic hydrogen. We find the room temperature resistance increases by about 4 orders of magnitude, a transition accompanied by anomalies in the momentum-resolved spectral function including a non-Fermi-liquid behavior and a breakdown of the quasiparticle picture. These effects are discussed in terms of a possible transition to a strongly (Anderson) localized ground state.

DOI: 10.1103/PhysRevLett.103.056404 PACS numbers: 71.30.+h, 72.15.Rn, 73.61.Wp, 79.60.–i

The interaction of atomic hydrogen with graphene is of fundamental interest. An H atom is expected to saturate a single C \(p_z\) orbital, forming a local \(sp^3\) atomic arrangement [1], which should significantly alter the local electronic structure due to the breaking of symmetry within the 2-atom basis set of the honeycomb unit cell. At high coverages, a band-insulating behavior has been predicted [2] and possibly observed [3]. On the other hand, at low coverages H or other point defects in graphene are predicted to lead to either magnetism [4] or a localized insulating state [5–9] depending on whether the H is arranged orderly or not.

Experimentally, low coverages of H on graphite lead to either isolated H monomers or dimers, depending on the dosing rate and temperature [10]. In this work, we prepare samples in the low-coverage, low-temperature monomer regime [10], with areal hydrogen density \(n_H \sim 10^{12} \text{ cm}^{-2}\), or around 0.1% coverage. While the clean graphene samples are metallic [11] with ordinary Fermi-liquid behavior [12], we find, through a unique combination of transport and angle-resolved photoemission spectroscopy (ARPES), that this behavior breaks down at a critical coverage \(n_H \sim 3 \times 10^{12} \text{ cm}^{-2}\) whereupon the samples become insulating, with room temperature resistance increasing by about 4 orders of magnitude.

Pristine metallic single-layer graphene samples were prepared either by annealing in UHV [12,13] or Ar [11]. While the data presented are for the UHV-prepared samples, the effects observed were similar for either method. Atomic H was decomposed from H\(_2\) gas passed through a tungsten capillary heated to about 2000 °C. The H pressure at the sample surface (held at \(T = 70^\circ\)K) is estimated by quadrupole mass spectroscopy to be \(3 \times 10^{-9}\) Torr. ARPES was conducted at the Electronic Structure Factory end station at beam line 7 of the Advanced Light Source.

Figure 1 shows the Fermi surface and band structure cuts of graphene as a function of H coverage. We find that the Fermi surface area decreases with H coverage, showing that atomic hydrogen acts as an acceptor, and providing a method to determine the coverage \(n_H\): with the assumption of one hole per H atom, then \(n_H\) is given by a geometrical factor times the change in Fermi surface area.

Quantitative analysis of graphene’s energy bands as in Ref. [12] shows striking trends with \(n_H\). Unlike ordinary chemical doping with potassium or NO\(_2\) [12,14], the bands do not shift rigidly with \(n_H\), but instead the Fermi surface area is reduced through a curious upturn of the upper \(\pi^*\) band above the Dirac crossing energy \(E_D\) (about 440 meV below the Fermi energy \(E_F\)), with little change to the \(\pi\) bands below \(E_D\) apart from a general broadening. This upturn of the bands implies that the density of states \(\mathcal{D}(\omega)\) is greatly reduced above \(E_D\); see Fig. 2(a) [15]. Such changes to the density of states depend on the details of the local electronic states around defects [16].

Moreover, the inverse mean free path (i.e. the momentum width \(\Delta k\) of the bands), increases far faster for the states above \(E_D\) than below [Fig. 2(b)]. At low \(n_H\), the lifetime is longest near the Fermi energy \(E_F\) (at \(\omega = 0\)), a sign of graphene’s ordinary Fermi liquid (FL) behavior [12]. But at higher \(n_H\), the lifetime is shortest near \(E_F\), inconsistent with a FL. Consequently, there is a rapid increase in the energy width \(\Delta \omega\) of the quasiparticle peaks near \(E_F\), as shown in Fig. 2(c).

In the quasiparticle approximation, scattering effects are sufficiently weak so as to preserve the freely propagating carriers. But for sufficiently high \(n_H\), we find \(\Delta \omega/\omega \gg 1\) as \(\omega \to 0\). This implies a complete breakdown of the quasiparticle picture, and evidently the states cannot be described as propagative above \(E_F\) for higher \(n_H\).

As a result of the rearrangement of spectral weight, the energy spectrum at the K point, which begins as a single peak in the pristine samples, apparently splits with \(n_H\) into
two peaks whose overall weight moves towards $E_F$ [see Fig. 2(d)]. This apparent splitting, however, does not reflect an actual energy gap or multiple states, but merely the rearrangement of overall spectral weight as the $\pi^*$ band moves towards the K point while simultaneously broadening. We have previously seen quite similar changes for underannealed, but hydrogen-free, graphene samples, and we ascribed these changes to unknown defects [17]. Indeed, the spectra for $n_H$ in Figs. 1 and 2 are practically the same as in Ref. [17]. This shows that the results we have found here may be generic to other kinds of point defects, not just those induced by H atoms.

We emphasize that ARPES data are hardly sensitive to any grain boundaries or step edges, which comprise a negligible part of the sample. And, we find no qualitative difference for H on nominally grain-free samples [11]. Therefore, the spectral features arise not from any boundary edge effects but are intrinsic to the bulk graphene. Since the same spectral features (a split energy distribution at the K point and a reduced Fermi surface area) are seen in islanded graphene samples [17–19], any interpretation of such spectral features in terms of island geometry or edge states would be debatable.

Fundamentally, the asymmetry with respect to $E_D$ arises from the position of a dispersionless hydrogen acceptor level, which is not centered at $E_D$ as for carbon vacancies (in a treatment without second neighbor hopping [16]) but instead $\sim 200$ meV above $E_D$ [4,9,20]. This state, although weak, is observed by comparing ARPES for the clean and disordered sample obtained far from the $\pi$ bands [Fig. 2(e)]; it imposes another particle-hole symmetry breaking factor discussed later.

Now we discuss the dosing dependence of the states near $E_F$ in more detail. Figure 3(a) shows the momentum distribution of the states at $E_F$ vs $n_H$. While at all coverages, the peak of the momentum distribution ($\sim k_F$) disperses towards the K point, at a critical coverage, the state abruptly broadens, reflected in a plot of the momentum width at $E_F$ in Fig. 3(b). Such an abrupt change does not occur for potassium atoms [data also shown in Fig. 3(b)], or for binding energies below $E_D$ (not shown) and reflects an abrupt transition of the spectral function.

We also observe a dramatic increase of sample resistance at this coverage, also shown in Fig. 3(b), measured as follows: in the photoemission experiment, a compensating current ($I \sim 10$ nA) travels from one side of the sample to the photoemission site [see Fig. 3(d)]. A resistance $R \geq 0.2$ MΩ along this path induces a measurable voltage shift $V = IR$ of the spectrum. Furthermore, by measuring the differential resistance at two spots, we could not only prove that the resistance arose within the graphene (and not, e.g.,

![FIG. 1 (color). Fermi surfaces (upper) and associated bandstructure cuts (lower) through the graphene K point for (a) clean, and (b)–(d) as a function of $n_H$ indicated in H atoms per cm$^2$. The dashed lines schematically show the Fermi surface contours. The solid lines in the lower row are the peak position determined by fits to the momentum distribution curves. The data were acquired with a slow flux of H atoms to compensate for photodesorption of H atoms.](image1)

![FIG. 2 (color online). (a)–(d) Variation of (a) DOS, fitted to lines, (b) momentum linewidth, (c) Energy distribution curves (EDCs) at $k_F$ and (d) EDCs at the K symmetry point. The series were acquired over 5 minutes under constant dosing conditions for the hydrogen coverages ($\times 10^{12}$ cm$^{-2}$) indicated in (d) with each trace averaged over 4 spectra at slightly different coverages. The horizontal lines indicate the baselines for each trace which are shifted for clarity. (e) Angle-integrated spectra for clean and dosed graphene, together with the difference spectrum, acquired $\sim 0.3$ Å$^{-1}$ away from the K point.](image2)
at the sample clip), but also accomplish the equivalent of a contact free, 4-point resistance measurement.

By varying the incident photon flux, we could measure a linear I-V relationship, demonstrating Ohmic resistance; see Fig. 4(a). More importantly, the temperature-dependent resistance $R(T)$ [Fig. 4(b)] displays insulating behavior (i.e., $dR/dT < 0$), thus ruling out that the sample is a “bad metal.” Since the pristine samples are metallic ($dR/dT > 0$) [11], we must conclude that the breakdown of the Fermi liquid and other anomalous spectral features occur at the same time as a metal-insulator transition (MIT).

What is the fundamental cause of the MIT? The reconstruction of the energy spectrum by H atoms, although dramatic, preserves the Fermi surface, and therefore formation of an ordinary band insulator such as graphite [2] is not supported by the data. We can similarly rule out other gap-inducing ground states such as density waves or Mott insulating behavior.

A similar defect density causes an MIT to an Anderson localization (AL) state in carbon nanotubes [21,22]. So it is tempting to ask whether we have induced an AL insulating state in graphene. Such a transition was predicted for graphene, depending on the symmetry class, density and range of the defects [5,6,9,23] and sample geometry [24]. While long-range impurities preserve the local lattice symmetry and suppress backscattering, leading to antilocalization [25], short-range impurities (those that, like H, break the symmetry of the graphene unit cell) lead to intervalley scattering, a significant backscattering, and, as a result, weak [26] or strong localization (i.e., AL).

Tight-binding calculations for graphene with on-site disorder show that a significant mobility gap (~400 meV) in the extended states can be developed for a modest density of short-range scatterers (~0.1%), comparable to our dosing level [7,8]. Such a mobility gap, if centered on the H acceptor level we observed, would reach $E_F$ and induce AL there. Renormalization group calculations for H on graphene also support the appearance of zero conductivity for similar coverages to what we observe [9].

The temperature-dependent resistance $R(T)$ is consistent with AL, since log $R$ is linear with $(1/T)^{1/3}$ [Fig. 4(b)], following Mott’s well-known relationship for a variable-range-hopping (VRH) model in 2D [27]. VRH is necessary as evidence for AL, but it cannot be regarded as sufficient proof in this case: First, the accessible temperature range did not give enough change in resistance for a conclusive analysis of the exponent; second, and more fundamentally, VRH transport does not occur only for AL, but also in any system with localized states such as disordered insulators or granular media.

However, the simultaneous measurement of ARPES with transport as a function of defect density not only rules out these other mechanisms, but the observed breakdown of the quasiparticle picture provides positive evidence for the AL transition in our samples. Since localized states are not quasiparticles, we expect a fundamental change in the spectral function upon localization [28], as we have observed. Whereas ordinarily the momentum width at $E_F$ reflects the mean free path of the quasiparticles, we propose that upon localization it should instead reflect the localization length of the electrons.

The linewidth analysis of the ARPES data [Fig. 3(c)] supports this picture. Here we plot the mean free path $L_{\text{mfp}}$ (i.e., the inverse momentum width at $E_F$) vs defect density $n_H$, and compare it to a hydrogen length scale given by $L_H = 1/\sqrt{n_H}$. Above the critical coverage, $L_{\text{mfp}}$ is limited by the distance between hydrogen atoms, as expected in
the above picture. The MIT occurs at a similar, but lower defect density than the simple prediction by Ioffe, Regel, and Mott, which predicts the MIT when $L_{mp} \sim 1/k_F$ [27,29], or, in our case, when $n_H \sim 6 \times 10^{12}$ cm$^{-2}$.

The presence of a dispersionless $H$ state [4,9,20] between $E_D$ and $E_F$ is of fundamental importance since it provides a microscopic model for how AL can take place. It explains the preferential broadening of the $\pi^*$ band due to an energy-dependent scattering cross-section [9,30], and it suggests that the energy distribution of localized states is not centered on $E_D$, as expected from the diverging de Broglie wavelength (and predicted within particle-hole-symmetric models [7,8]) but is instead biased to the $\pi^*$ states near $E_F$ [9].

Some subtle changes to the spectral functions in Fig. 1 can now be explained within this model. The kinks and associated linewidth variations in the bands due to electron-phonon interaction, studied in detail for metallic graphene [12,31] are clearly preserved in the metallic state, but become washed out in the insulating state, another clear breakdown of the quasiparticle picture. In contrast, defects normally show up as an additional, uncorrelated scattering term in the electronic self-energy and do not much affect the electron-phonon kinks [32]. Intriguingly, the kink disappears not through some overall reduction in its strength, but rather by an apparent reduction in its energy scale; i.e., the band kinks at an energy progressively closer to $E_F$. This may reflect the motion of an underlying mobility edge in the extended states towards $E_F$.

A recent ARPES study of graphene claimed to induce an MIT by lowering $E_F$ into a pseudogap near $E_D$ [14]. In a recent transport study [3], a much higher $H$ dose than we used ($\sim 50\%$ coverage) was claimed to create a disordered insulator state, characterized by clustering of $H$ atoms correlated to ripples. Both of these systems were described as ordinary insulators created by chemical means, although with ambiguity about the actual resistance in the first study [14], and about the bandstructure, density and distribution of defects in the second [3]. In contrast, our finding of an insulating transport coexisting with an intact Fermi surface is inconsistent with such a band insulator in our case and provides tantalizing evidence in support of the AL ground state.

This conclusion if true suggests promising directions for future research. Access to the momentum-dependent spectral function can open a new experimental window onto the role and interplay of interactions with the Anderson localization transition. While we have studied randomly placed defects, one can envision a patterned deposition of $H$ atoms, or even the atomically-controlled placement of defects using scanning probe manipulation, so that many important aspects of localization theory could be studied systematically. As an easily prepared material, accessible not only to transport and gating but also a variety of surface probes, our results suggest that graphene is a new paradigm for resolving open questions about conductance in disordered materials.